DAN



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Confirmation No. 9935

Hiroto YUKAWA et al.

Docket No. 2003_1079

Serial No. 10/630,744

Group Art Unit 1752

Filed July 31, 2003

Examiner Sin Lee

POSITIVE-WORKING CHEMICAL-AMPLIFICATION PHOTORESIST COMPOSITION

RESPONSE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 OMMISSIONER IS AUTHORIZED PAGE ANY DEFICIENCE SE OR THIS PAPER TO DEPUSED A OF TINO, 23-0975

Sir:

In response to the Official Action dated May 17, 2004, please amend the present application as follows:

